**ERRATA**

*Equilibrium Shape of Si*  
*[Phys. Rev. Lett. 70, 1643 (1993)]*

D. J. Eaglesham, A. E. White, L. C. Feldman, N. Moriya, and D. C. Jacobson

The Si step energy of 28 ± 10 meV/atom determined from the curvature of small voids near (100) should more properly be compared with half of the double $A$-type step energy (i.e., 0.5×50 meV/atom [1]), as opposed to the single $B$-type step energy (23 meV/atom) used in this paper. The authors would like to thank Dr. H. J. W. Zandvliet for pointing this out.


*Singular Behavior of Shear Flow Far from Equilibrium*  

A. Santos, V. Garzó, J. J. Brey, and J. W. Dufty

The matrix $L$ given by Eq. (13) has two misprints: the element (5,9) should be $-\frac{\rho}{a}$ rather than $\frac{\rho}{a}$ and the element (7,6) should be $a$ rather than $-a$. The results reported in the paper have been obtained from the correct matrix $L$.

The numerical value given in the paper for the diagonal element $c_3(a)$ is based on numerical calculations done by Ikenberry and Truesdell [J. Rat. Mech. Anal. 5, 1 (1956)]. A more accurate evaluation [Z. Alterman, K. Frankowski, and C. L. Pekeris, Astrophys. J. Suppl. Ser. 7, 291 (1962/3)] yields $c_3(a) = 4a(a) + 1.873\nu$, which leads to a modified value for the critical shear rate: $a_c \approx 6.845\nu$.

0031-9007/94/72(9)/1392(1)$06.00  
© 1994 The American Physical Society

*Surface-Tension-Gradient-Induced Pattern Formation in Monolayers*  

Mu Wang, G. Wildburg, J. H. van Esch, P. Bennema, R. J. M. Nolte, and H. Ringsdorf

We regret that there was a misspelling on the name of the last author. It should be H. Ringsdorf. The correct names of the authors should read as follows: Mu Wang, G. Wildburg, J. H. van Esch, P. Bennema, R. J. M. Nolte, and H. Ringsdorf.